

10/522162

DT15 Rec'd PCT/PTO 24 JAN 2005

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

**Daniel MEISEL et al.**

International Appln: PCT/EP2003/007819

U.S. Application No.: Not Yet Assigned

For: METHOD FOR THE PRODUCTION  
OF PHOTORESIST STRUCTURES

Art Unit: Not Yet Assigned

Examiner: Not Yet Assigned

Confirmation No.: Not Yet Assigned

**Atty. Docket No.: 31775-210910 RK**

Customer No.: **26694**

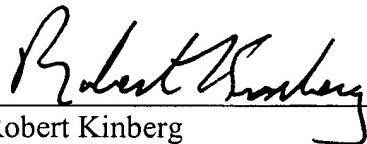
**Submission of Formal Drawings**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Submitted herewith are two (2) sheets of formal drawings containing Figs. 1-2.

Respectfully submitted,

  
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Date: January 24, 2005

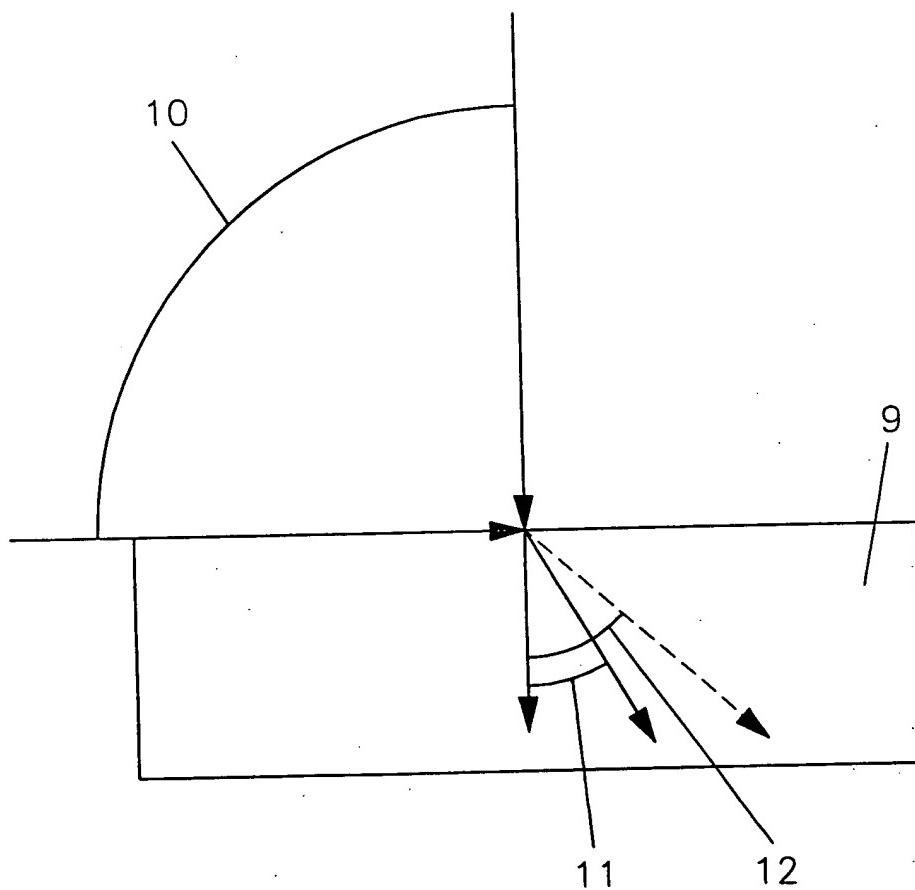
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Inventor: Daniel MEISEL et al.  
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Fig. 1



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Fig. 2

